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CERAM
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PHOTOCURABLE SOL-GEL FORMULATIONS FOR ADDITIVE MANUFACTURING OF CERAMICS

Alice Zanini¹, Luca Avanzi^{1,2}, Michele Ballan², Stefano Corradetti²,
Paolo Colombo¹, Giorgia Franchin¹

¹University of Padova, Department of Industrial Engineering, Padova, Italy

²Istituto Nazionale di Fisica Nucleare – Laboratori Nazionali di Legnaro, Legnaro (PD), Italy

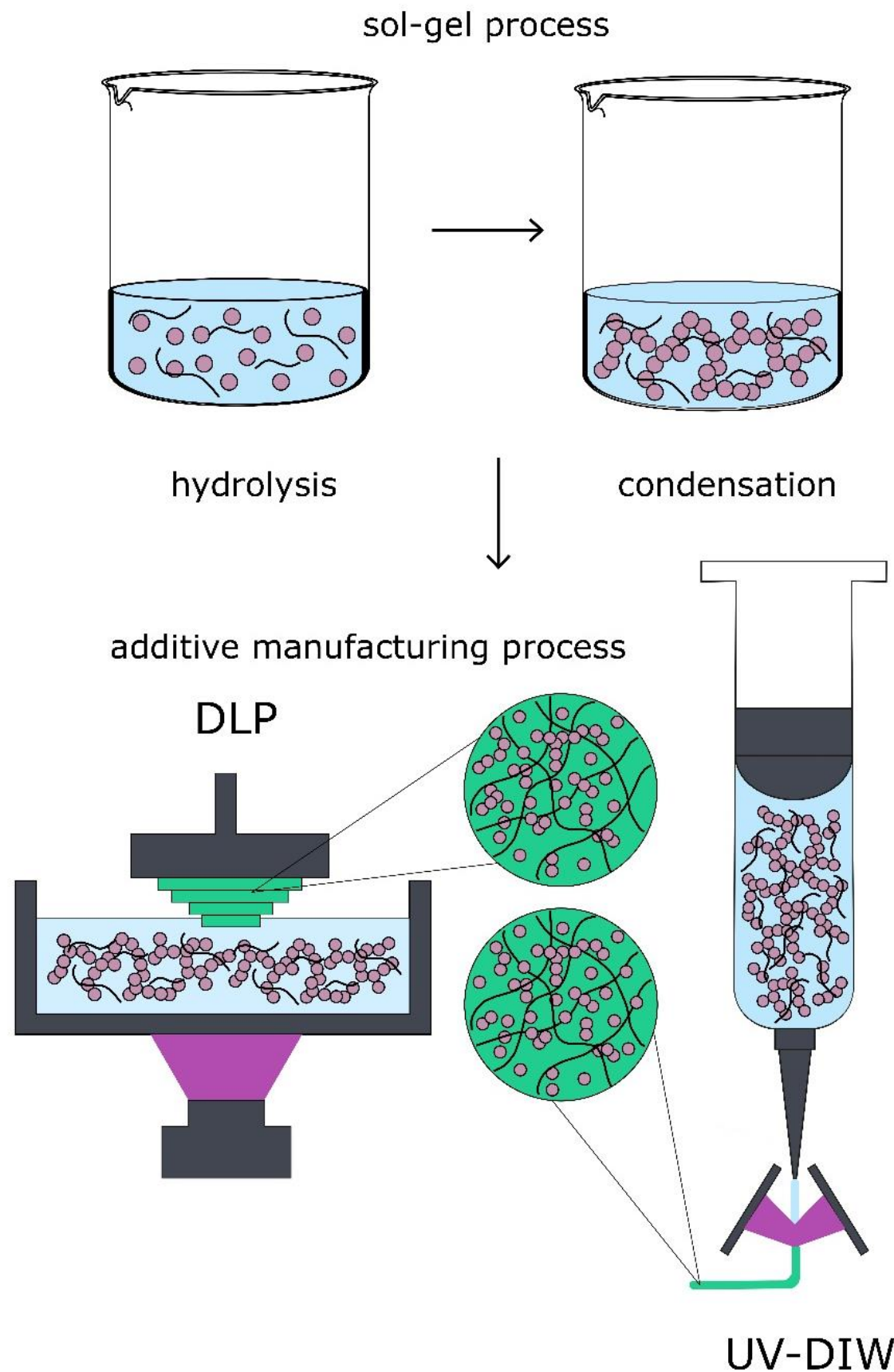
Conventional powder-based approaches

- fine ceramic powders to be **dispersed** in aqueous and non-aqueous slurries
 - **high viscosity** even with a limited amount of powder ($\sim 40\%_{\text{vol}}$)
- green bodies with adequate strength
 - significant amount of **organic binders**
 - delicate debinding processes and limited wall thickness and volume
- **particle size** limits the resolution, feature size and surface quality
- **light scattering** limits the resolution and penetration depth (DLP, SLA)

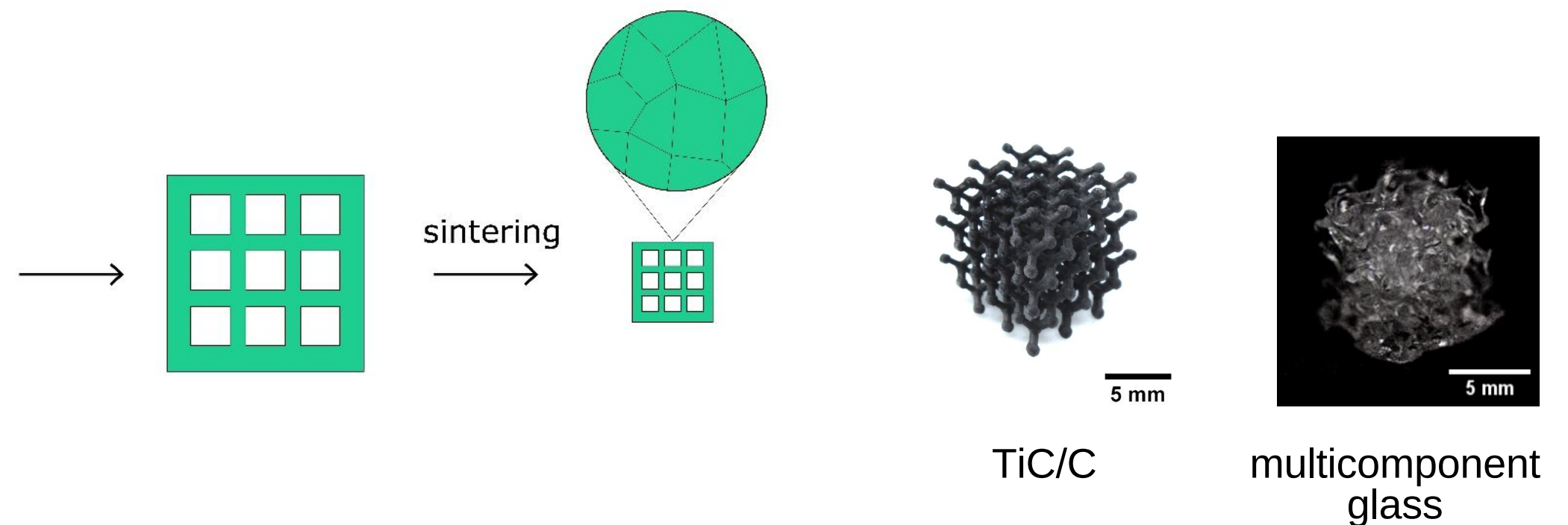
Liquid feedstock

- liquid systems exploit the **more advanced stage of development** of AM technologies for polymers
- densification occurs at **lower temperatures** and generally results in **denser bodies**
 - stronger and more reliable parts
 - unique material properties retained (i.e. glass transparency)
- **not suitable for all AM technologies** (BJ, ~~SLS/SLM~~, ~~DED~~)

Sol-gel compositions for AM processes



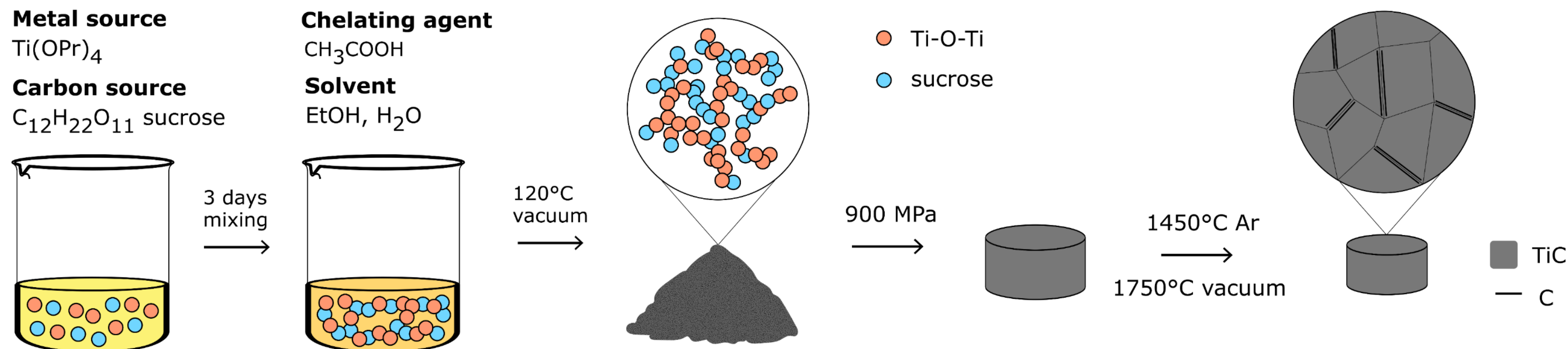
- chemical versatility
- **high homogeneity** of the final product
- material design by assembling molecular **building blocks**
- **fine tuning** of the material properties
- preventing clogging of the tip during extrusion-based processes
- control on reactivity by **tailoring synthesis parameters**: temperature, pH, catalyst system, precursor:solvent ratio



DLP of hierarchically porous carbide/carbon nanocomposite

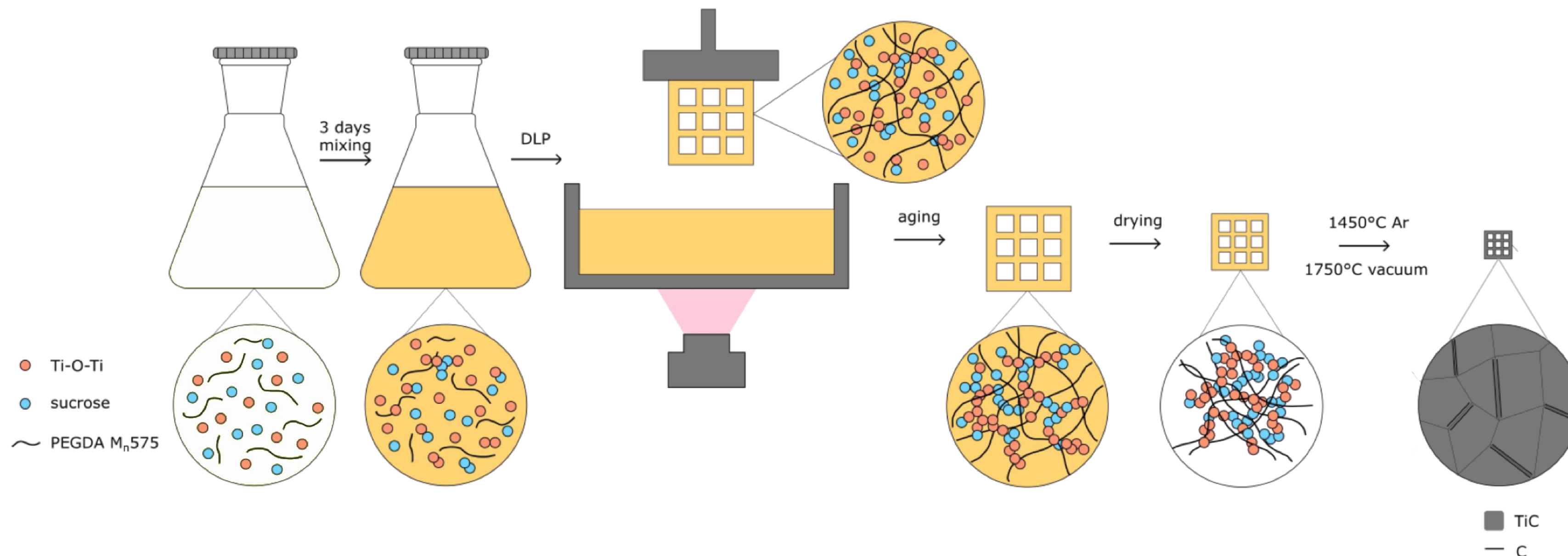
- *note:* carbide powder-based suspensions produce light adsorption and scattering
→ hindered photopolymerization and penetration depth
- *application:* targets for isotope on-line separation (ISOL) facilities
→ nuclear physics and radiopharmaceutical applications

Highly microporous TiC/C nanocomposite



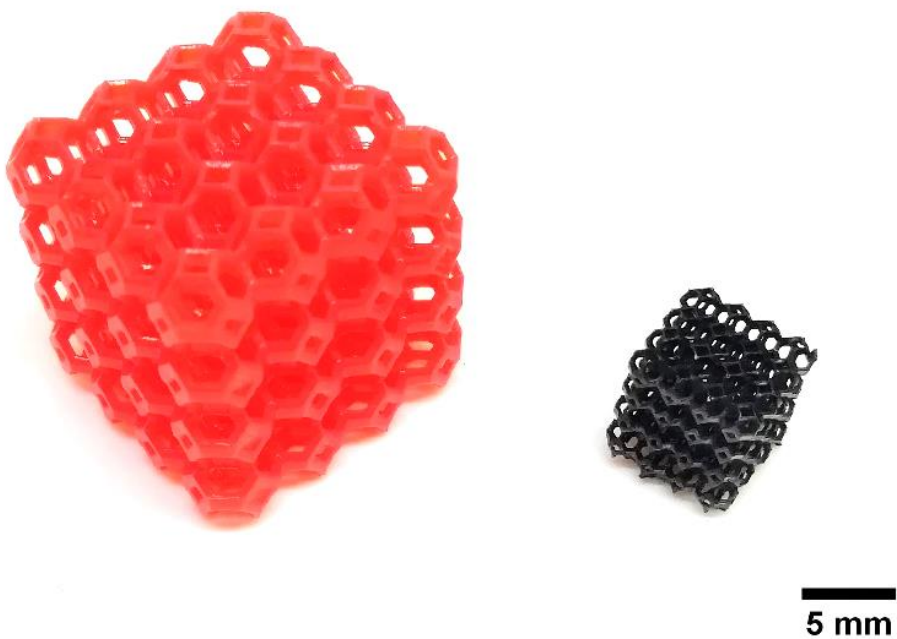
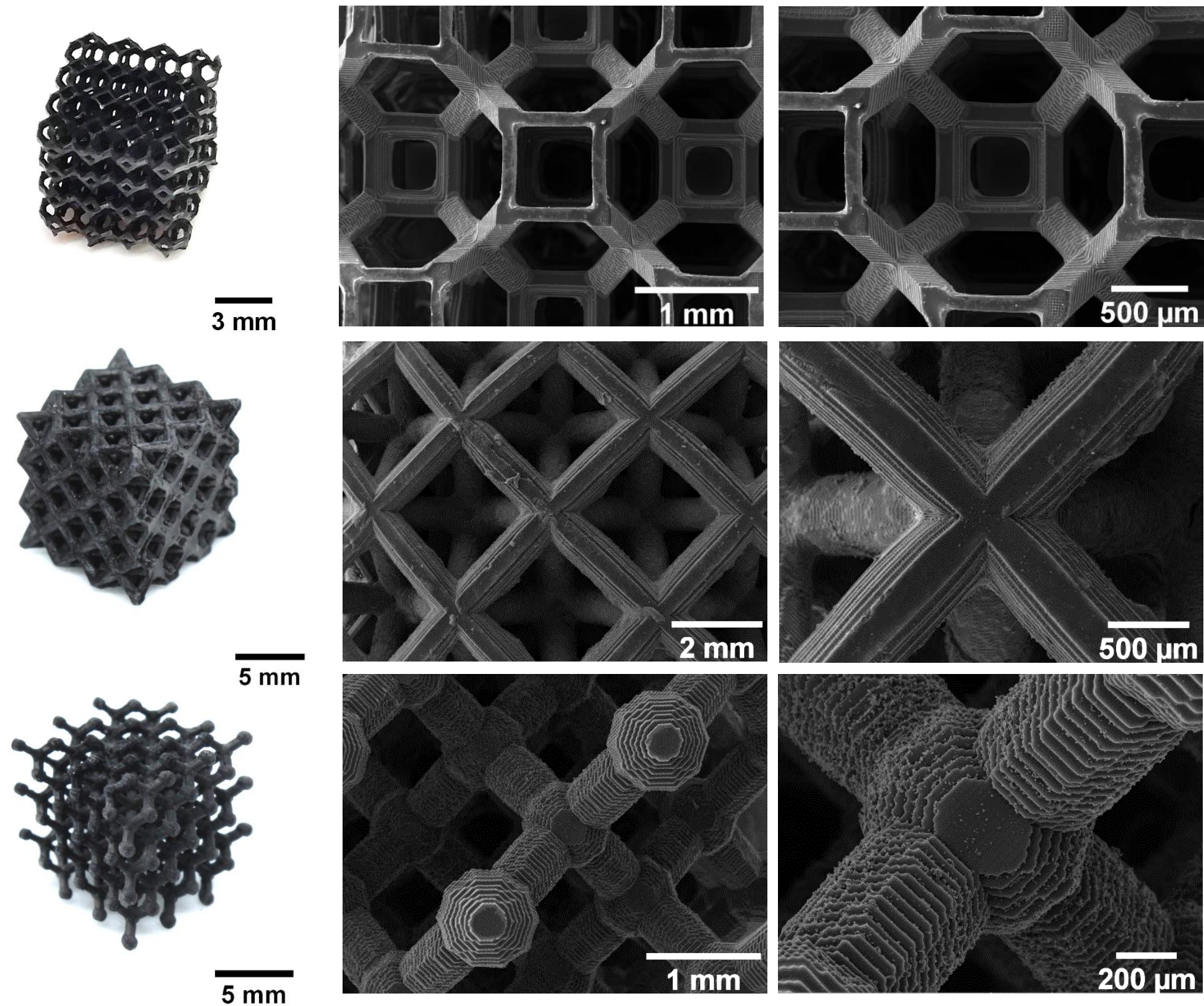
- metal and carbon precursors + carbothermal reduction → highly porous carbide
- overstoichiometric carbon content: $\text{TiO}_2 + 5\text{C} \rightarrow \text{TiC} + 2\text{C} + 2\text{CO}$
 - excess **C** = turbostratic structure
 - thin sheets at the grain boundaries of **TiC nanocrystals** (22 nm)
- total porosity: **64%** (97% of which open)
- SSA (BET): **655 m²/g**, micropores fraction: **84%**

Photocurable ink for AM of TiC/C nanocomposite



- **physical blend** of the sol and a photocurable acrylate (PEGDA) to promote fixation by photopolymerization reactions
- formation of **2 separate, interpenetrating networks** (sol-gel and photopolymerization-derived)

DLP of structured hierarchically porous TiC/C nanocomposite

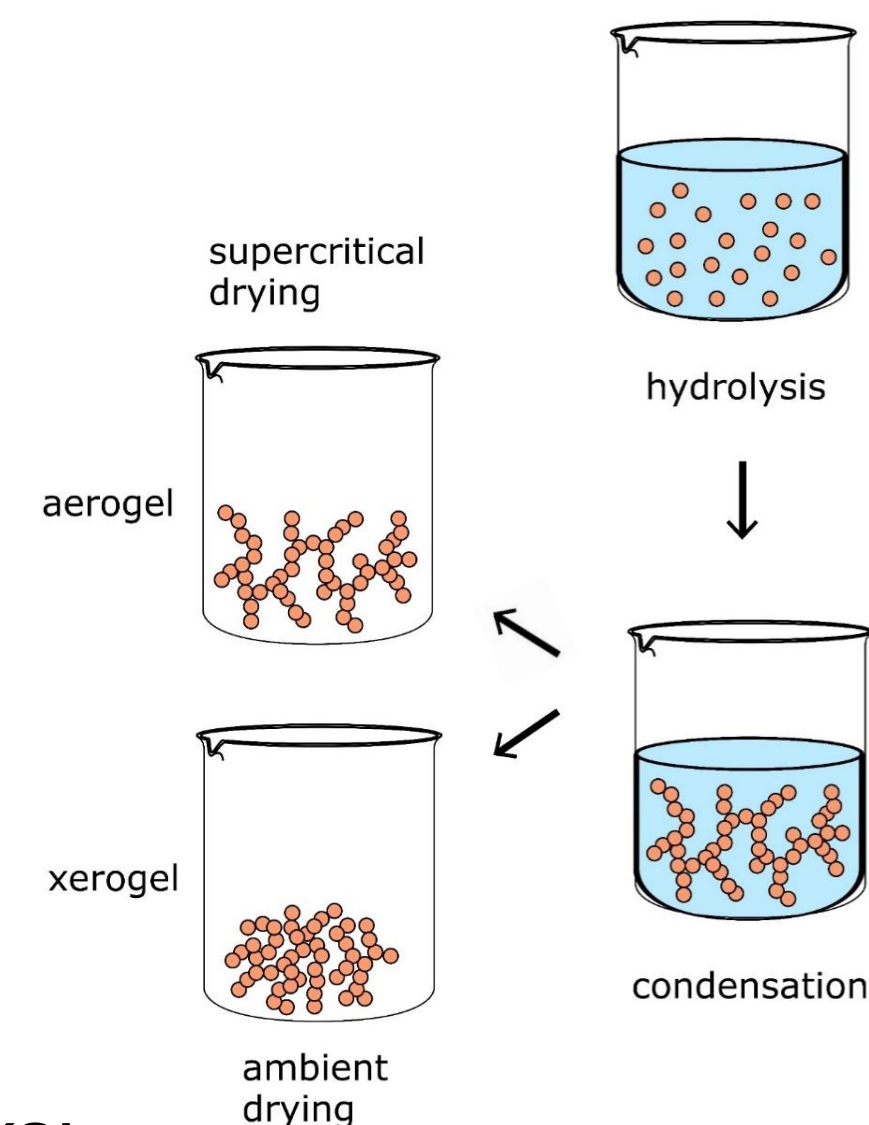
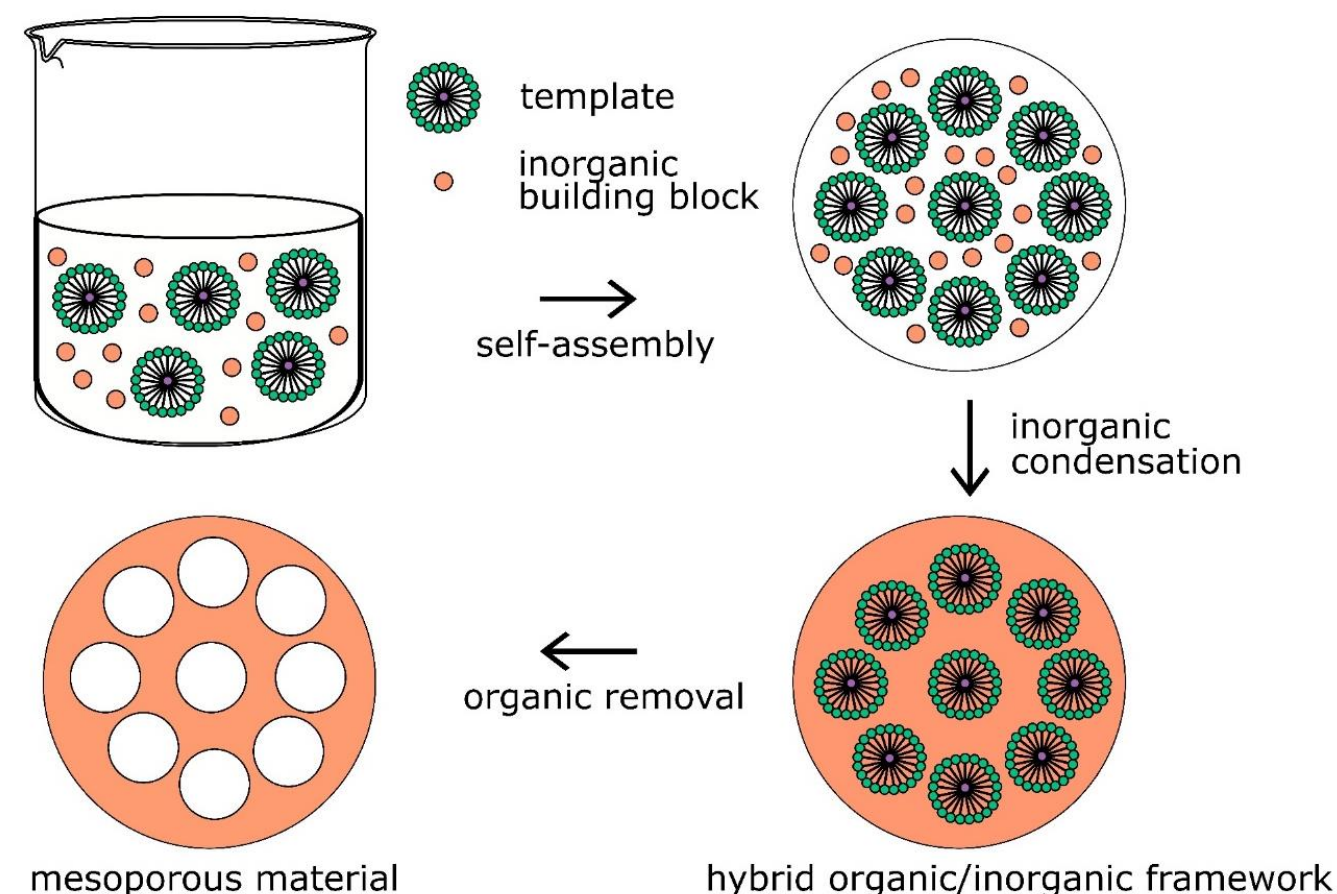


- crack-free samples upon sintering at 1750°C
- dense struts and no residual porosity
- homogeneous shrinkage along x-y and z direction

weight loss [%]	91.1 ± 0.7
xy shrinkage [%]	56.7 ± 0.1
z shrinkage [%]	56.7 ± 0.1
volumetric shrinkage [%]	91.9 ± 0.1

DLP of structured hierarchically porous TiC/C nanocomposite

- **volumetric shrinkage** of photopolymer upon photopolymerization
→ textural changes in the final material SSA (BET): **149 m²/g**



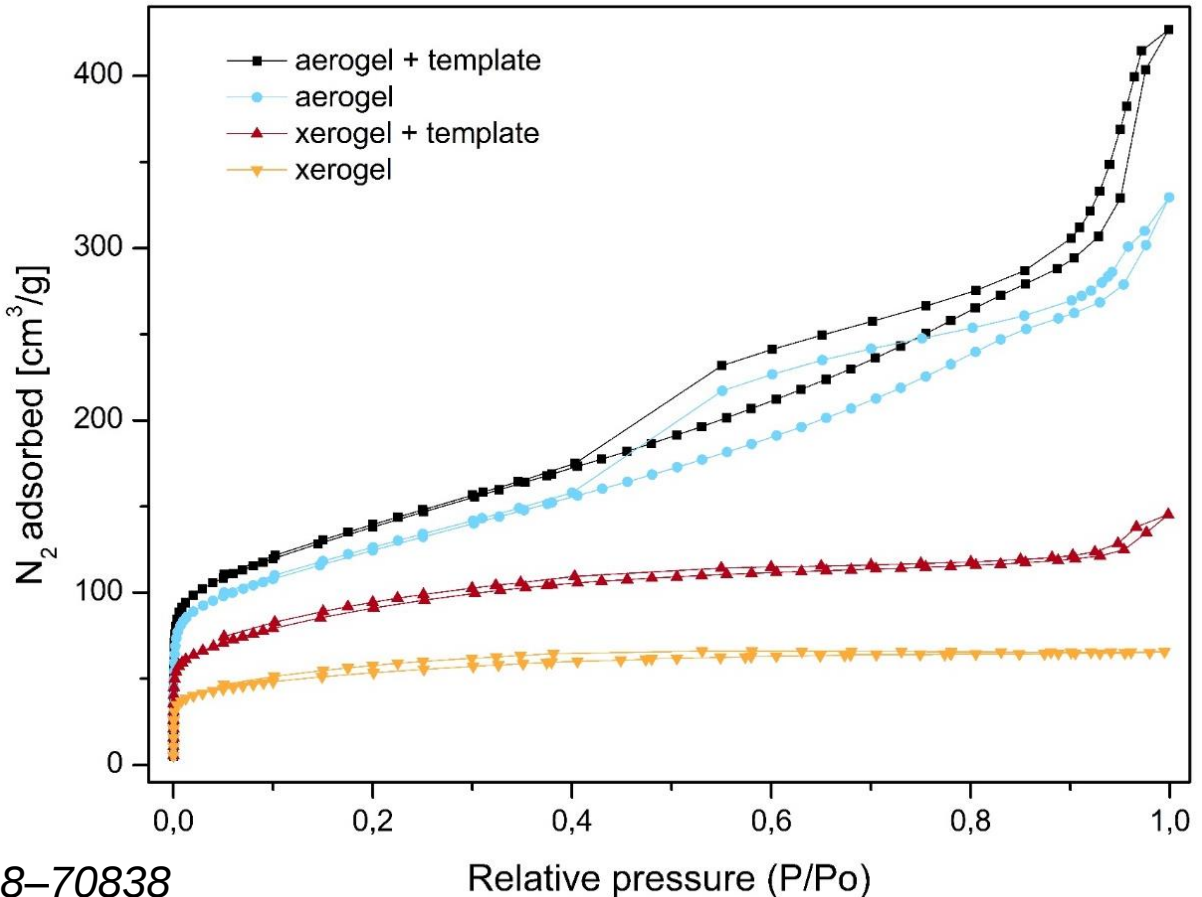
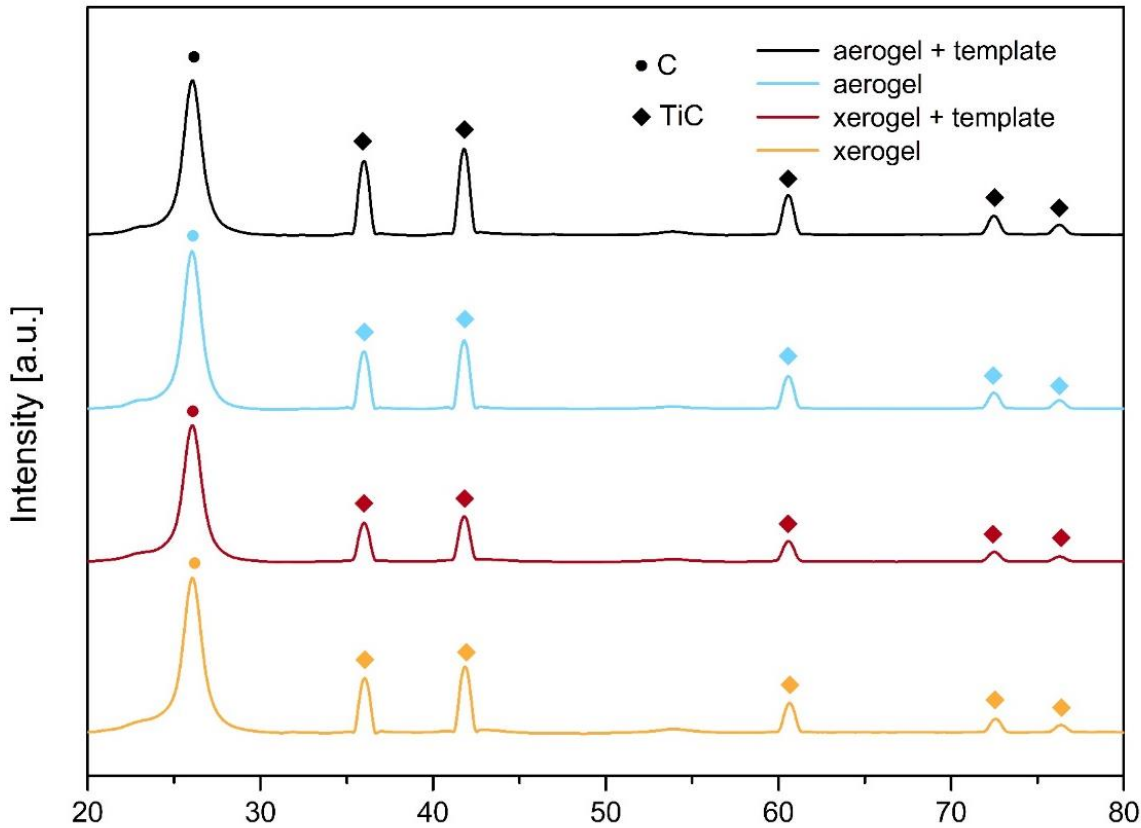
→ control over the **local arrangement** of the molecular building blocks:

- EISA (evaporation induced self-assembly)
- supercritical drying
- cooperative EISA + supercritical drying

DLP of structured hierarchically porous TiC/C nanocomposite

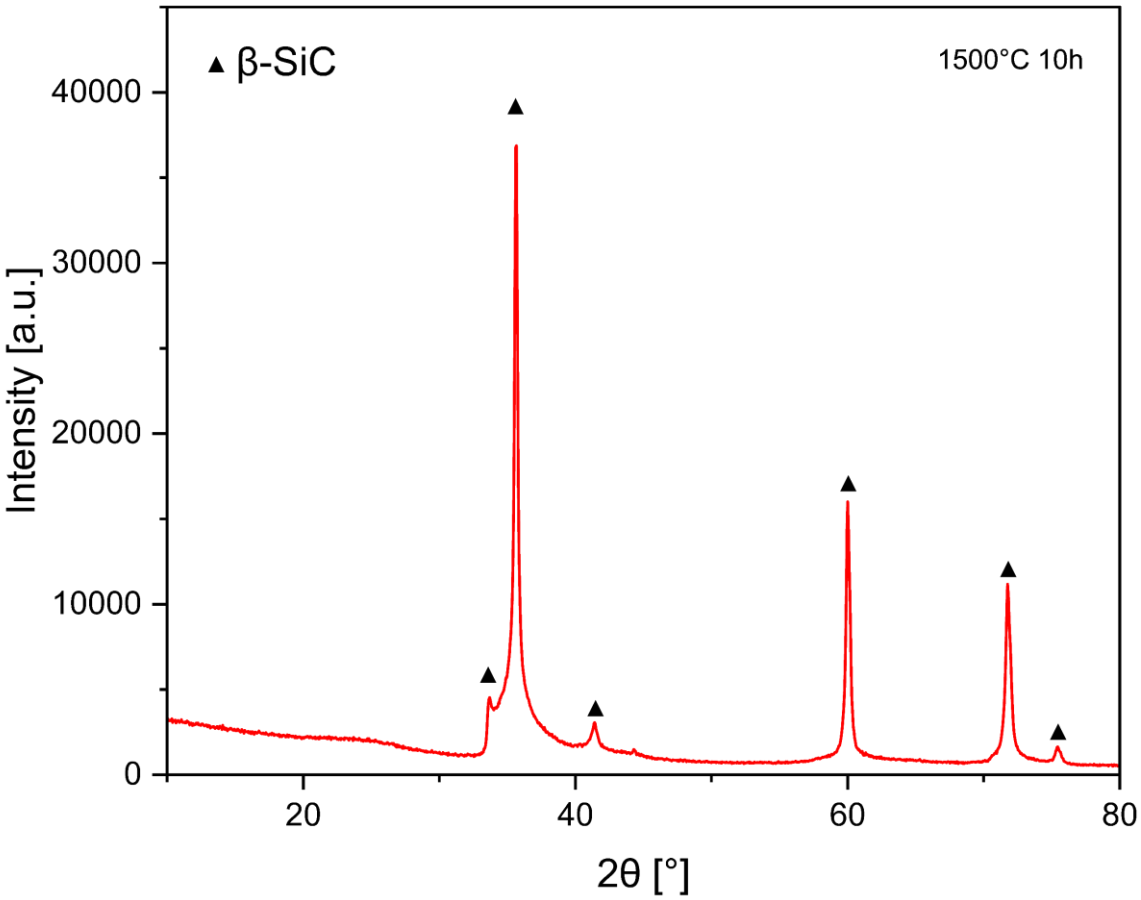
- overstoichiometric carbon content: $\text{Ti} : \text{C} = 1 : 5$
 - **TiC nanocrystallites** (13 nm)
 - **nanocrystalline graphite** (7 nm) with turbostratic structure
- **textural control** and design of **bimodal porosity**:
 - aerogel route → mesopores > micropores
 - xerogel route → mesopores < micropores

fabrication route	SSA _{BET} [cm ³ /g]	V _{micro} [%]
xerogel	149	71
xerogel + EISA	328	57
aerogel	391	21
aerogel + EISA	403	18

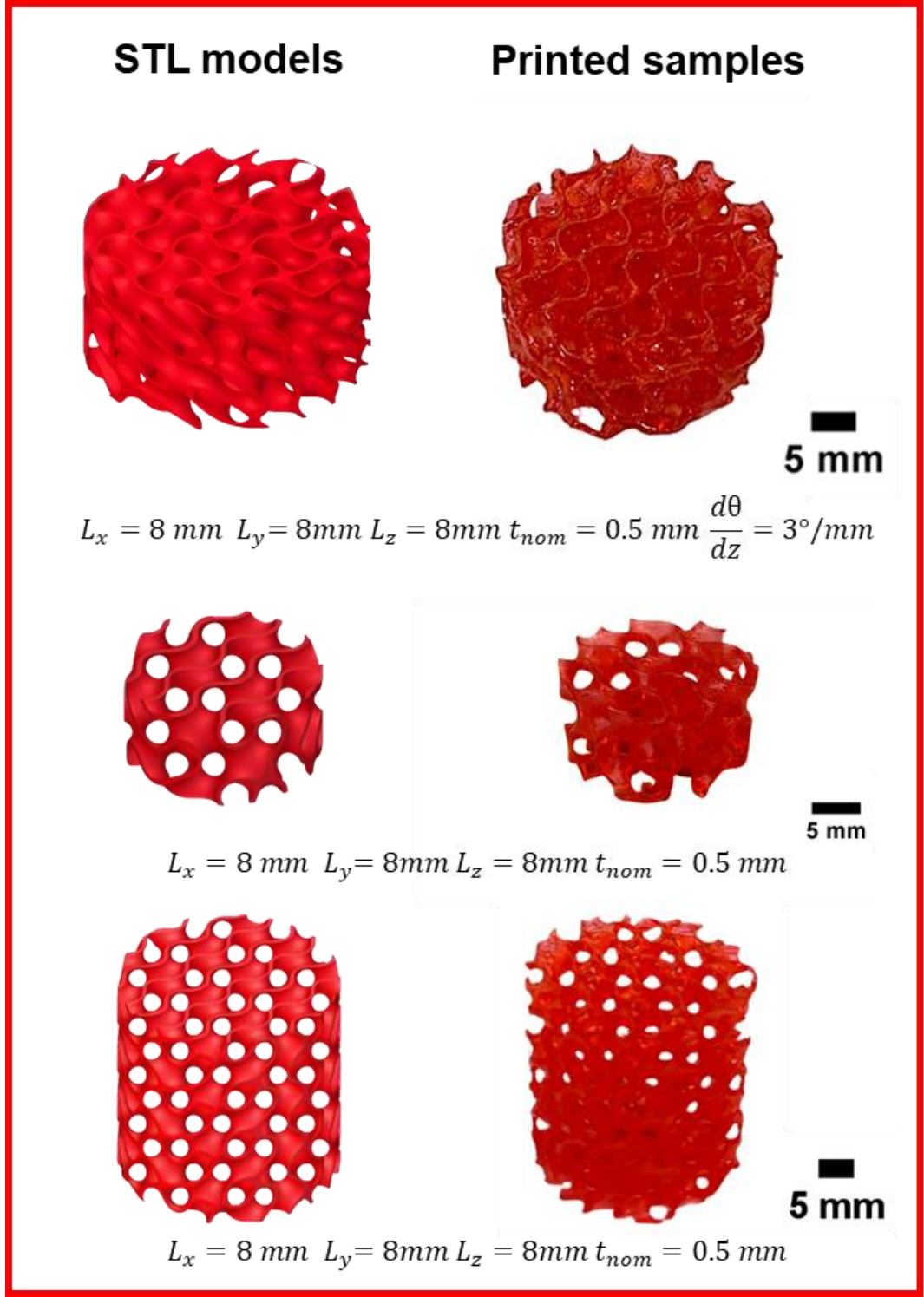


Current research: nanostructured SiC

- stoichiometric carbon content:
 $\text{Si} : \text{C} = 1 : 1$
 - TEOS + sucrose (~ TiC)
 - other hybrid Si-C precursors
- thermal treatment @ 1500°C for 10h in high vacuum



Precursors	SSA _{BET} [cm ³ /g]	Crystallite size [nm]
TEOS + sucrose	42	27
other	372	26

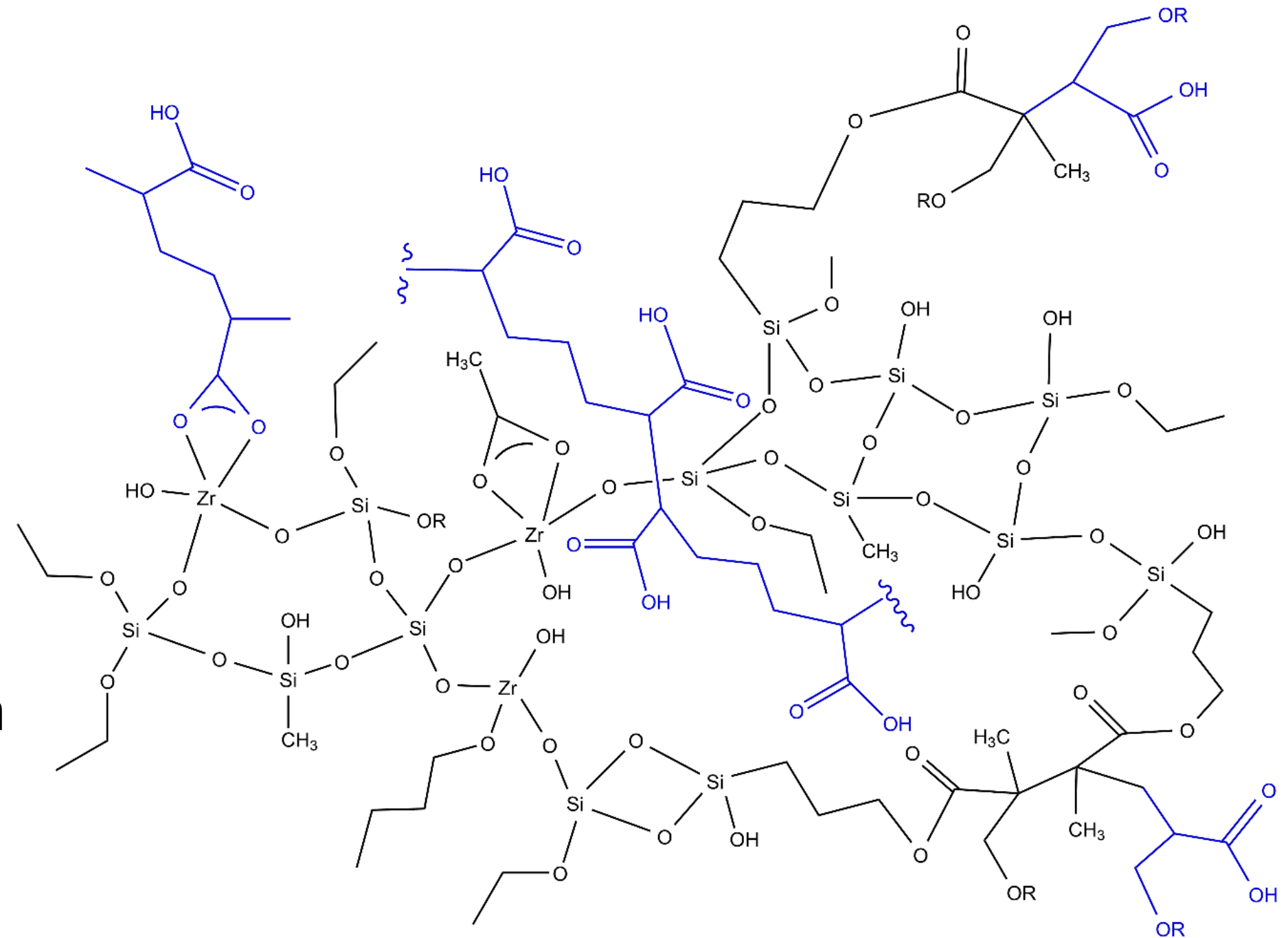


DLP and UV-DIW of dense multicomponent glass

- high transmittance
- compositional versatility
 - tuning of refractive index and other optical properties
- *application*: jewelry, optics

Photocurable sol-gel formulations for multicomponent glass

- **Si precursors:** alcoxides
 - *hydrolizable groups:* hydrolysis/condensation
 - *non-hydrolizable groups:* chain flexibility
 - **acrylate groups:** photopolymerization (interconnected networks)
- **Transition metal precursors:** alcoxides
 - Zr, Ti to increase the refractive index
- **Non-hydrolizable acrylate monomer:** partial decoupling of the two networks to turn material rigidity and response to stresses
- **High boiling point solvent:** transient porosity to favor binder burnout



DLP of high refractive index glass



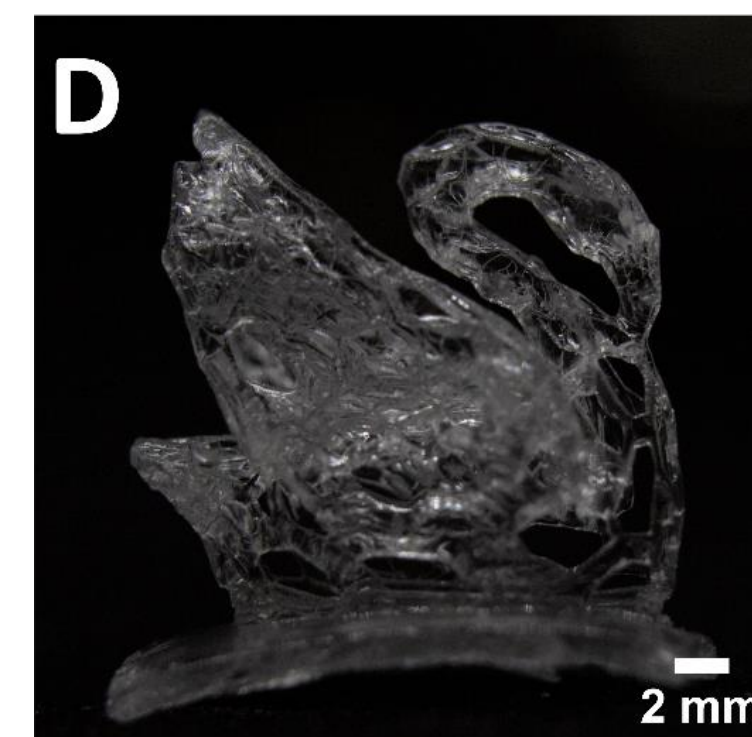
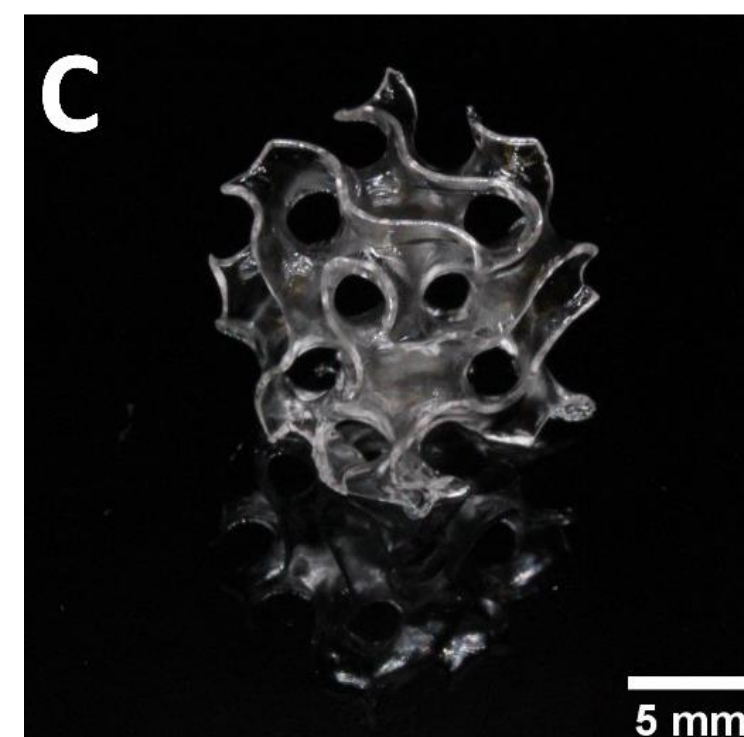
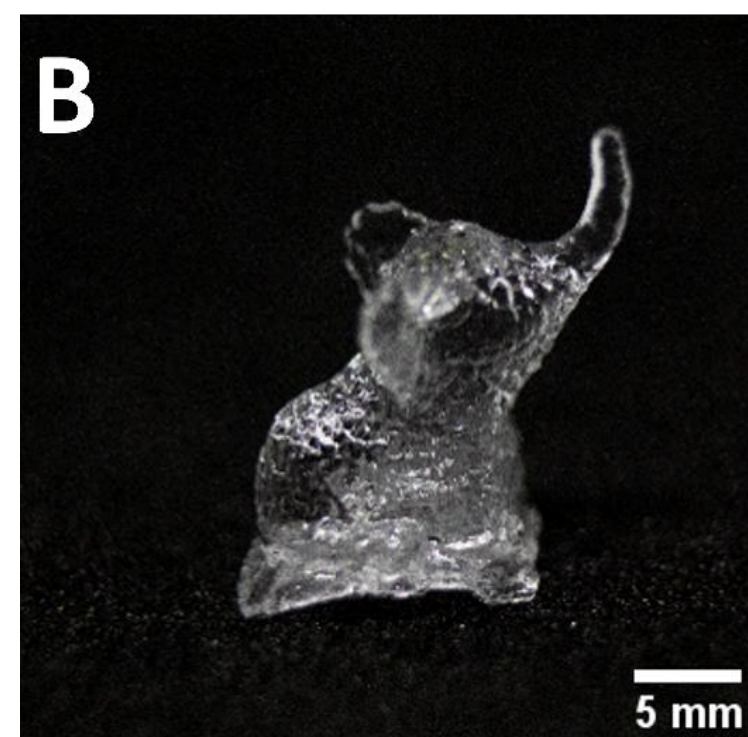
- precursors: SiO_2 , ZrO_2 and TiO_2
- acid catalysis
- Si-alkoxide-acrylate + organic acrylate
- sintering T: 1000°C

n_d : ~ 1.55 to ~ 1.57

transmittance_{@405 nm}:
 ~ 90.5 to 98.8%

density: ~ 2.55 to 2.72 g/cm^3

Abbe number: $v_d \sim 41.3$ to 60.4

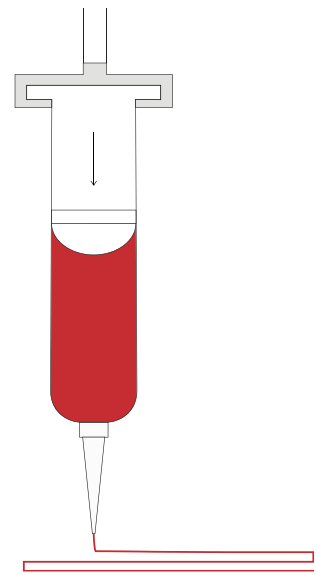


Patent pending (Swarovski) - PCT/EP2024/051082

Hybrid UV-DIW technology

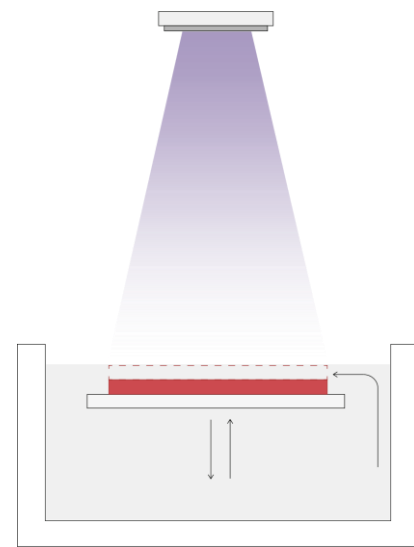
Hybrid additive manufacturing technology as a combination between **Direct-Ink Writing (DIW)** and **UV photo-polymerization**

Direct Ink Writing



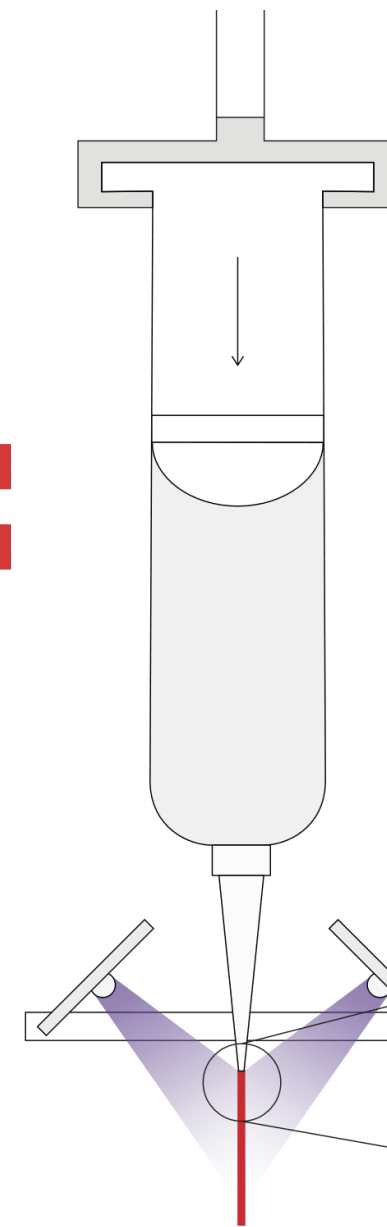
- ✓ Fast printing
- ✗ Ink preparation

Vat photo-polymerization



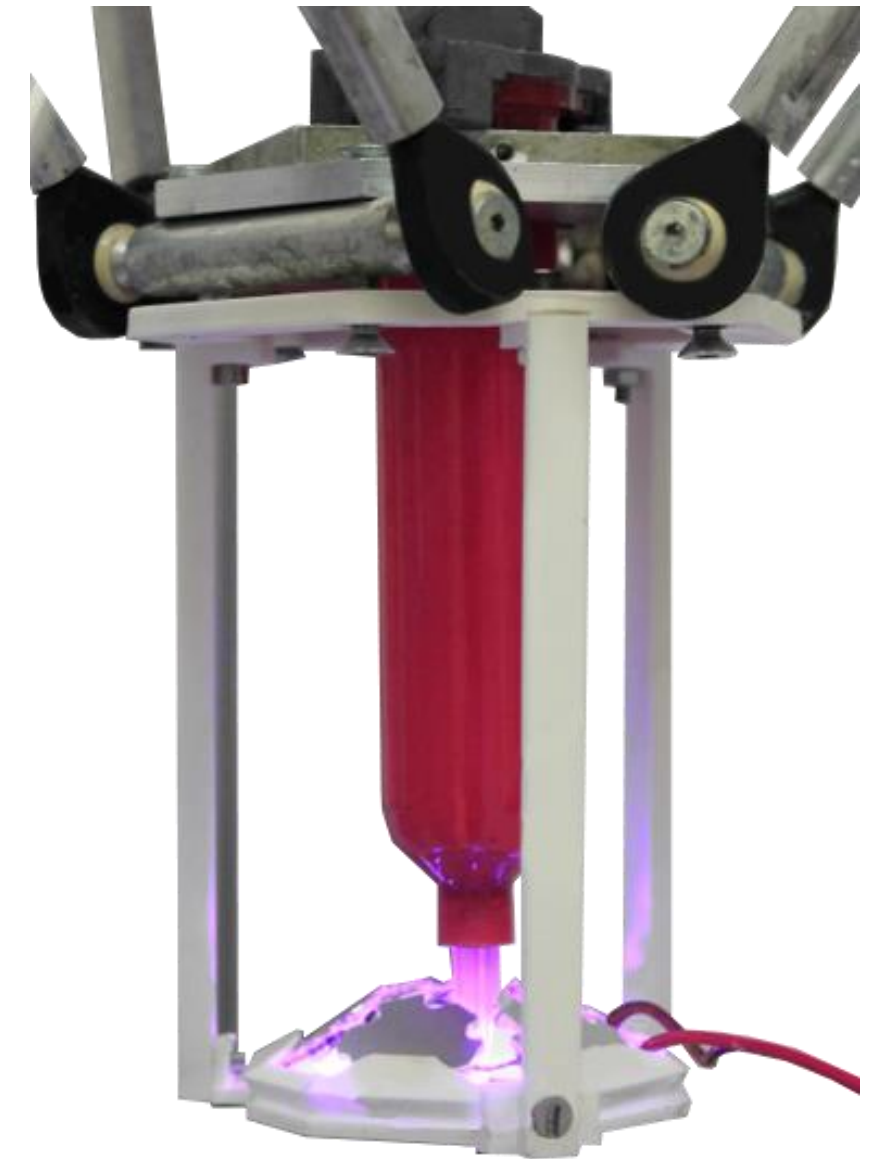
- ✓ High resolution
- ✗ Light scattering

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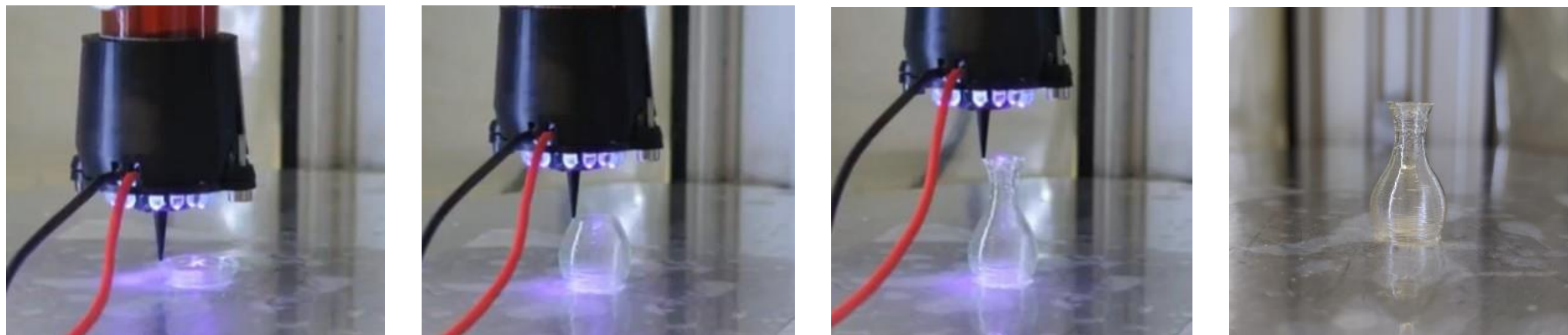


Final design

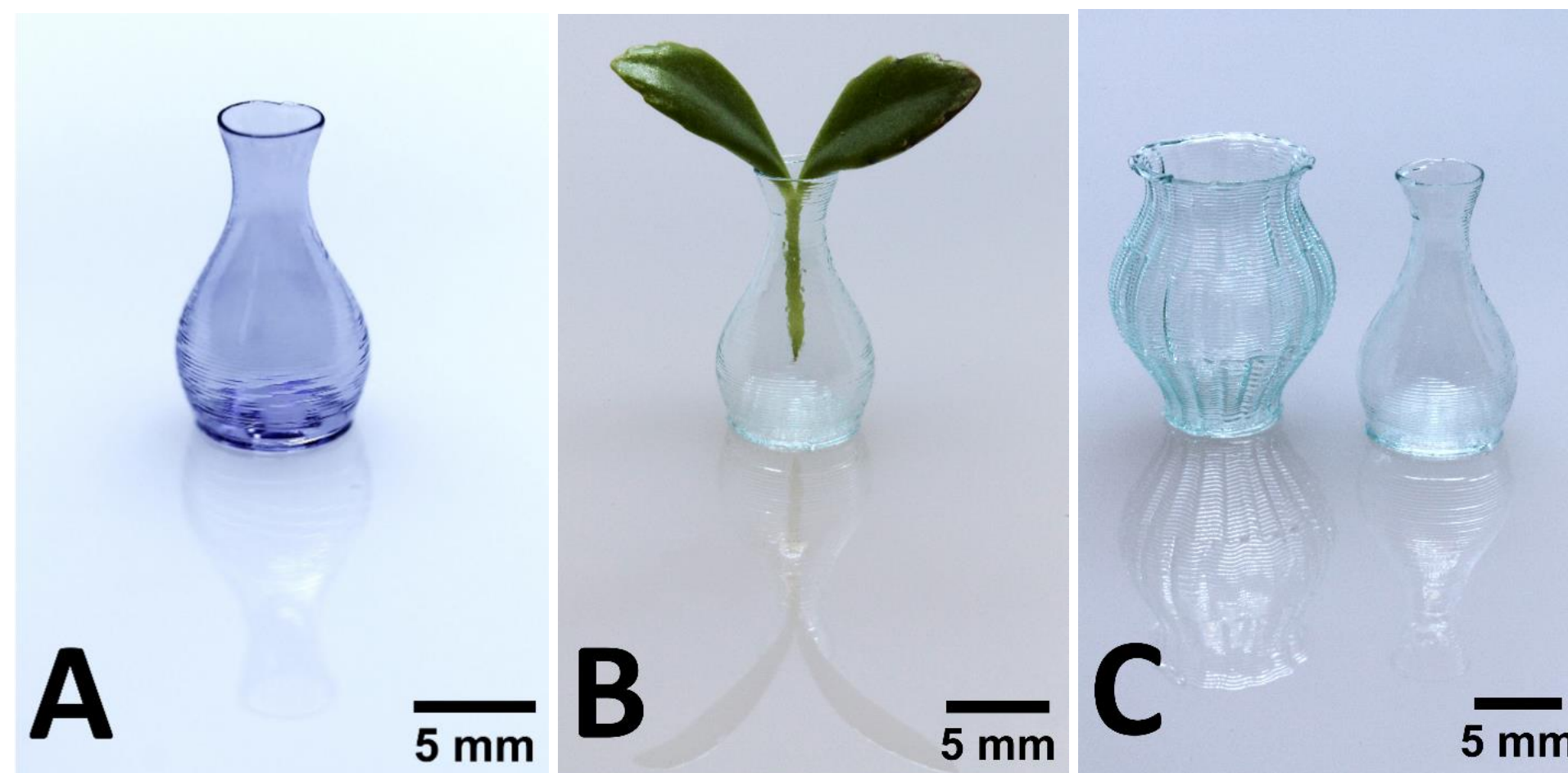
- ✓ High resolution
- ✓ No light scattering
- ✓ Fast printing
- ✓ Free-forming structures



UV-DIW of high refractive index glass



- precursors: SiO_2 , ZrO_2 and TiO_2
- acid catalysis
- Si-alkoxide-acrylate
- *addition of bulk coloring pigments*
- solvent evaporation step: tune ink viscosity
- sintering T: 1000°C
→ colored glass



Patent pending (Swarovski) - PCT/EP2024/051082

Summary and conclusions

- AM of **sol-gel compositions** demonstrates the potential of **liquid feedstock** for a facile production of **porous** and **dense** ceramic components:
 - **sols** can be rendered photocurable and exploited for **DLP** as well as other photopolymerization-based AM technologies
 - **gel formation** develops **rheological properties** suitable for **DIW**
 - hybrid **UV-DIW** technology
 - generation of **two co-continuous networks** (which can be separate or interconnected):
 - one **organic** (based on photopolymerized acrylates)
 - one **inorganic** (based on condensed M-OH groups from hydrolyzed metal alkoxides)
 - **composition design** to control solvent evaporation, reactivity, printing, drying, debinding and sintering
- + high **versatility** in terms of **composition** and **microstructural development**
- + structures with **controlled** (non stochastic) and **hierarchical** architectures



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giorgia.franchin@unipd.it